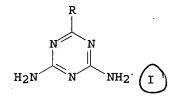
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ΔN
    1987:479048 CAPLUS
    107:79048
DN
    Entered STN: 05 Sep 1987
ED
ΤI
    Epoxy resin compositions
    Hino, Hirohisa; Fukui, Taro; Hashimoto, Shinji; Tsujimoto, Masaya
IN
PA
    Matsushita Electric Works, Ltd., Japan
SO
    Jpn. Kokai Tokkyo Koho, 6 pp.
    CODEN: JKXXAF
DТ
    Patent
    Japanese
LA
IC
    ICM C08G059-50
    ICS H01L023-30
CC
    38-3 (Plastics Fabrication and Uses)
    Section cross-reference(s): 76
FAN.CNT 1
    PATENT NO.
                       KIND
                             DATE
                                        APPLICATION NO.
                                                              DATE
    -----
                       ----
                             -----
                                        ------
                                                              -----
    JP 61246227
                       A2
                             19861101
                                        JP 1985-89414
                                                              19850424
                             19850424
PRAI JP 1985-89414
CLASS
               CLASS PATENT FAMILY CLASSIFICATION CODES
 PATENT NO.
               ----
                      ______
 JP 61246227
               ICM
                      C08G059-50 ·
               ICS
                      H01L023-30
```



GI

AB One-package liquid title compns. with fast curing rate, useful for potting semiconductor elements, contain dispersed powdered acetoguanamine or benzoguanamine (I) latent hardeners and fillers. Thus a mixture of 100 parts ELA 127 (bisphenol A epoxy resin) and 25 parts I containing 60% fused silica was kneaded under vacuum to prepare an one-component

epoxy resin composition Standard Al-patterned chip elements
potted with the composition at 190° for 24 h, required 240 h to 50%
failure in the thermal breakdown test (85°, 85% relative humidity,
15V d.c. bias), compared with 50 h for the elements potted with a similar
epoxy resin composition containing 10 parts dicyandiamide instead
of I.

ST one package epoxy resin potting; benzoguanamine latent hardener epoxy potting; semiconductor epoxy potting hardener; rapid curing epoxy potting

IT Potting compositions

(epoxy resins containing guanamine latent hardeners and silica as, for semiconductors)

IT Semiconductor devices

(potting compns. for, one-package epoxy resins containing guanamine latent hardeners as, fast-curing)

IT Epoxy resins, uses and miscellaneous

RL: USES (Uses)

(bisphenol A-based, potting compns. based on, fast-curable one-package, containing guanamine derivative latent hardeners and fillers, for semiconductors)

IT Crosslinking agents

(latent, guanamines as, epoxy resins containing,

fast-curable for potting semiconductor elements)
91-76-9, Benzoguanamine 542-02-9, Acetoguanamine
RL: USES (Uses)
(latent hardener, one-package epoxy resins containing, fast-curable for potting semiconductor elements)
IT 108916-47-8, ELA 127-benzoguanamine copolymer 109315-74-4, ELA 127-acetoguanamine copolymer
RL: USES (Uses)
(potting with compns. based on, fast-cured one-package, of semiconductor devices)

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RN
     542-02-9 REGISTRY
ED
     Entered STN: 16 Nov 1984
     1,3,5-Triazine-2,4-diamine, 6-methyl- (9CI) (CA INDEX NAME)
CN
OTHER CA INDEX NAMES:
     s-Triazine, 2,4-diamino-6-methyl- (6CI, 8CI)
OTHER NAMES:
CN
     2,4-Diamino-6-methyl-1,3,5-triazine
CN
     2,4-Diamino-6-methyl-s-triazine
CN
     2,6-Diamino-4-methyl-s-triazine
CN
     2-Methyl-4,6-diamino-s-triazine
CN
     6-Methyl-1,3,5-triazine-2,4-diamine
CN
     Acetoguanamine
CN
     ENT 50715
CN
    NSC 257
FS
     3D CONCORD
MF
     C4 H7 N5
CI
     COM
LC
                  BEILSTEIN*, CA, CAOLD, CAPLUS, CASREACT, CHEMCATS,
     STN Files:
       CHEMINFORMRX, CHEMLIST, CSCHEM, IFICDB, IFIPAT, IFIUDB, PROMT, SPECINFO,
       TOXCENTER, USPATZ, USPATFULL
         (*File contains numerically searchable property data)
                     DSL**, EINECS**, TSCA**
    Other Sources:
         (**Enter CHEMLIST File for up-to-date regulatory information)
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$$H_2N$$
 $N$ 
 $N$ 
 $N$ 
 $N$ 
 $N$ 
 $N$ 

## \*\*PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT\*\*

- 310 REFERENCES IN FILE CA (1907 TO DATE)
- 51 REFERENCES TO NON-SPECIFIC DERIVATIVES IN FILE CA
- 311 REFERENCES IN FILE CAPLUS (1907 TO DATE)
- 22 REFERENCES IN FILE CAOLD (PRIOR TO 1967)

DERWENT-ACC-NO:

1986-329492

DERWENT-WEEK:

198650

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TITLE:

One pack epoxy! resin for sealing semiconductor elements

- contg. guanamine deriv. as curing agent

PATENT-ASSIGNEE: MATSUSHITA ELECTRIC WORKS LTD [MATW]

PRIORITY-DATA: 1985JP-0089414 (April 24, 1985)

PATENT-FAMILY:

PUB-NO

PUB-DATE

LANGUAGE

PAGES

MAINIPC

JP 61246227 A

November 1, 1986

N/A

006

N/A

APPLICATION-DATA:

PUB-NO

APPL-DESCRIPTOR

APPL-NO

APPL-DATE

JP 61246227A

N/A

1985JP0089414

April 24, 1985

INT-CL (IPC): C08G059/50, H01L023/30

ABSTRACTED-PUB-NO: JP 61246227A

## BASIC-ABSTRACT:

Compsn. consists of a liq. epoxy resin, an epoxy curative and a filler; the improvement comprises that a guanamine cpd. with curing potentiality of formula (I) is used as a curative and the curative is dispersed in the epoxy resin as it is powder together with the filler. In (I) R is Ph and/or CH3. Pref., the epoxy resin contains under 20 ppm of Na(+) plus Cl() ions and under 0.1% of hydrolysable Cl. The content of the filler is pref. 3080 wt.% and the filler contains pref. under 200 ppm Na(+) and under 20 ppm Cl(-). The content of the curative is 10-30 PHR on the basis of the epoxy resin when R is Ph and 525 PHR when CH3.

USE/ADVANTAGE - A rapid curing compsn. with excellent properties for sealing semiconductor and discrete circuit elements directly on a board, capable of storage and sealing with a dispenser.

CHOSEN-DRAWING: Dwg.0/0

TITLE-TERMS: ONE PACK POLYEPOXIDE RESIN SEAL SEMICONDUCTOR ELEMENT CONTAIN

GUANAMINE DERIVATIVE CURE AGENT

DERWENT-CLASS: A21 A85 E13 L03 U11

CPI-CODES: A05-A01B1; A08-D03; A08-R01; A12-E04; A12-E07; A12-E07C; E07-D13B;

L04-C20A;

EPI-CODES: U11-A07;

CHEMICAL-CODES:

Chemical Indexing M3 \*01\*

Fragmentation Code

F012 F014 F016 F580 G010 G100 H1 H01 H122 L910 L999 M113 M210 M211 M240 M280 M281 M320 M413 M510 M521 M530 M531 M540 M781 M903 Q132 Q454 R036

Ring Index

00212

UNLINKED-DERWENT-REGISTRY-NUMBERS: 1694U; 1694U

PAT-NO:

JP361246227A

DOCUMENT-IDENTIFIER:

JP 61246227 A

TITLE:

EPOXY RESIN COMPOSITION

PUBN-DATE:

November 1, 1986

INVENTOR-INFORMATION:

HINO, HIROHISA FUKUI, TARO HASHIMOTO, SHINJI

TSUJIMOTO, MASAYA

ASSIGNEE-INFORMATION:

COUNTRY

MATSUSHITA ELECTRIC WORKS LTD

N/A

APPL-NO:

JP60089414

APPL-DATE:

April 24, 1985

INT-CL (IPC): C08G059/50, H01L023/30

US-CL-CURRENT: 528/118

## ABSTRACT:

PURPOSE: The titled composition which has properties necessary for sealing, semiconductor elements, can be stored in the form of a onecomponent composition, can be applied in sealing with a dispenser and is excellent in rapid curability, comprising a liquid epoxy resin, a filler and a specified curing agent.

CONSTITUTION: A liquid epoxy resin (A) having Na<SP>+</SP> and Cl<SP></SP> ion contents ≤20ppm, respectively, and a hydrolyzable chlorine content ≤1ppm is mixed with 30∼80wt% filler (B) (e.g., alumina) of a Na<SP>+</SP> ion content &le;200ppm and a Cl<SP></SP> ion content &le;20ppm and 5∼ 25 PHR powdered guanamine compound (C) of formula I (wherein R is formula II or CH<SB>3</SB>) as a curing agent having latent curability. Component C in the mixture is dispersed in the form of a powder.

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